

## A 140GHz power amplifier with 20.5dBm output power and 20.8% PAE in 250-nm InP HBT technology

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## mm-wave Communication (140-1000 GHz)

- Objective
  - -Support high data rate communication.
  - -Spatial multiplexing for high capacity.
  - -Cover long distance.
- Benefits (140- 1000 GHz)
  - -Large available spectrum, high data rate.
  - -Shorter  $\lambda$ : more channels for the same array size.
- Challenge

-Atmospheric attenuation is high  $P_R \alpha \frac{\lambda^2}{R^2} e^{-\alpha R}$ .





## PA Requirments and Link Budget

- CMOS chips drives high efficiency InP power amplifiers
- CMOS's output power is ~2dBm
- 20.5dBm output power per element extends the link range to ~50m
- Required gain ~20dB
- Massive MIMO arrays requires high efficiency PAs to avoid thermal destruction or complex heatsink



Tx Antenna Gain	22.7 dBi		
Rx Antenna Gain	13 dBi		
Link range	50 m		
Required output power per element	20.5dB <sub>m</sub>		
Friss Path Loss	73 dB		
Rx Noise Figure	8.5 dB		
Rx BW	5 GHz		
Bit rate	10 Gb/s		
System Margin	15 dB		
No of elements, Tx ( $\lambda/2$ spacing)	32		
No of elements, Rx ( $\lambda/2$ spacing)	4		

calculated data are based on

https://www.ece.ucsb.edu/Faculty/rodwell/Classes/ece218c/ECE218c.htm

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## **ANGELES** 250nm InP HBT Process (Teledyne<sup>\*</sup>)

- f<sub>max</sub>=650GHz.
- BV<sub>CE0</sub>=4.5V.
- $J_{max}=3mA/\mu m$ .
- Four Au interconnect.
- MIM cap (0.3fF/µm2).
- TFR (50 $\Omega$ /square).



\*M. Urteaga, et al, Proc. IEEE, June 2017.





## Unit Cell Comparison

- Comparison between CE, grounded CB and CB with base capacitor
- Simulation is done under same bias condition
- Large signal simulation is more relevant in power amplifier
- CB with base capacitor shows the highest  $OP_{1dB}$  with associated PAE

	Gain*, dB	PAE**, %	P <sub>out</sub> **, dB <sub>m</sub>
CE	10.7	15.4	12.0
Grounded CB	13.1	22.4	13.5
CB with 600 cap	9.8	29.7	15.2

\*under opt load line condition without compression \*\*at 1dB gain compression



WE1C-5



## Unit Cell Comparison

- Common emitter
  - Lowest  $\text{OP}_{1\text{dB}}$  and Soft compression
  - Less sensitive to base inductance errors
- Common base with grounded base
  - Higher gain and  $OP_{1dB}$
  - Requires –ve supply-> huge efficiency drop (large DC current in Re)
  - Bias is very sensitive without Re due to exponential relation ( $I_{CE}$  vs  $V_{BE}$ )
  - sensitive to base inductance errors
- Common base with base capacitance
  - Highest PAE and  $OP_{1dB}$  due to capacitance feedback linearization
  - Capacitance help stabilization (not shown)
  - Stable bias: negligible efficiency due to  $\mathsf{R}_\mathsf{b}$  ; base current is very small
  - Gain drops with smaller capacitance

	Gain*, dB	PAE**, %	P <sub>out</sub> <sup>**</sup> , dB <sub>m</sub>
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CB with base capacitor



# CB viewed as stacked PA cell\*

- $C_{CB}$  and  $C_{base}$  creates negative feedback
- This negative feedback
  - –Linearize the amplifier: higher PAE and  $OP_{1dB}$
  - Allows voltage swing on the base:
    with proper design, the output swing increases
    yielding in higher output power
  - -Drops the output impedance: improves S22



### PA unit cell/ stack analogy





- Assuming lossless matching network
- Internal voltages and currents are constant by proper load and base impedances\*
- $2(n-1)\omega P_{add}C_{base} = X_1X_2\sin(Y_1 Y_2)$ (derivation not shown)



• 
$$P_{out} = P_{add} + P_{in}$$

 $X_1$  is the magnitude of  $I_1$  $X_2$  is the magnitude of  $I_2$  $Y_1$  is the angle of  $I_1$  in radians  $Y_2$  is the angle of  $I_2$  in radians

C<sub>base</sub>



\*A. Ahmed, et al, EUMIC 2018.

Pout



- Common base with base capacitance
- Capacitance dropped slightly
  - -More power and hard compression
  - -lower output impedance (better S22)
- Shunt stub tunes the transistor parasitics
- Two cells are combined and driven by a single driver-> better PAE
- ADS and HFSS are used for the interconnect and matching circuit simulations



Two combined PA cells





- Higher base capacitance:
  - more gain
- Input ant output are  $50\Omega$  matched
- Staggered matching for wider bandwidth







Transmission line combiner instead of Wilkinson

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- Proposed combiner
  - Low loss and very compact
  - Smaller BW compared to Wilkinson
- Wilkinson
  - Bulky, high loss and skinny line
  - Higher BW







## PA block diagram

- Three linearized common base stages
- Low loss and compact transmission line combiner
- First driver scaled to sustain good PAE
- Independent bias for each stage to monitor the current and optimize the PAE

### 1.08mmx0.63mm



Chip micrograph







- Wide band operation
- 1dB BW=20GHz
- 3dB BW=43GHz

V <sub>CC1</sub>	V <sub>CC2</sub>	V <sub>CC3</sub>	V <sub>BB1</sub>	V <sub>BB2</sub>	V <sub>BB3</sub>
2.5V	2.5V	1.5V	1.94V	1.36V	1.1V
I <sub>CC1</sub>	I <sub>CC2</sub>	I <sub>CC3</sub>	I <sub>BB1</sub>	I <sub>BB2</sub>	I <sub>BB3</sub>
121mA	52mA	31.8mA	4.1mA	1.7mA	0.95mA



Measured (solid) vs simulated (dotted) S-parameters





- P<sub>sat</sub>=20.5dB<sub>m</sub>, and PAE=20.8%
- P<sub>sat</sub> =18.9-20.5dB<sub>m</sub> over 125-150GHz









## **State-of-the-art results**

### Highest PAE for comparable P<sub>sat</sub> and gain

Ref	Technology	Freq (GHz)	P <sub>sat</sub> (dBm)	BW <sub>3dB</sub> GHz <sup>++</sup>	Gain at P <sub>sat</sub> (dB)	Peak PAE %	Size (mm <sup>2</sup> )	P <sub>DC</sub> (W)	P <sub>sat</sub> /Area mW/mm <sup>2</sup>
[2]	40 nm CMOS	140	14.8	17	13**	8.9	0.34	0.3	88.8
[4]	130-nm SiGe HBT	155-180	18.0	25	23.5**	4.0	0.85	1.57*	74.2
[5]	130-nm SiGe HBT	112-142	17+	16	29**	13+	1.06	0.39*	47.2
[6]	130-nm SiGe HBT	131-180	14	49	22**	5.7	0.48	0.44*	52.3
[7]	250-nm InP HBT	110-150	23.2-24.0	32.7	14-16	5.8-7.0	1.89	3.46	134
[8]	250-nm InP HBT	115-150	21-21.8	34.8	15-17.5	8.2-10.5	0.75	1.54	205
This work	250-nm InP HBT	125-150	18.9-20.5	43	12.3-15.9	14.3-20.8	0.69	0.52	162





- Demonstration of record PAE at D-band
- Teledyne 250nm InP HBT has high  $\rm f_{max}$  and  $\rm BV_{CEo}$
- Capacitively linearized common base
  - -Higher  $OP_{1dB}$ , and PAE
  - -Easier to bias and stabilize
- Compact and low loss transmission line network
- Driver scaling and bias optimization





- This work was supported in part by the Semiconductor Research Corporation and DARPA under the JUMP program.
- The authors thank Teledyne Scientific & Imaging for the IC fabrication. The authors would like to thank Zach Griffith for valuable insight and design review.





[1] M. J. W. Rodwell et al., "100-340GHz Systems: Transistors and Applications," 2018 IEDM, San Francisco, CA, 2018.

[2] D. Simic and P. Reynaert, "A 14.8 dBm 20.3 dB Power Amplifier for D-band Applications in 40 nm CMOS," RFIC, Philadelphia, PA, 2018, pp. 232-235.

[3] A. A. Farid, A. Simsek, A. S. H. Ahmed and M. J. W. Rodwell, "A Broadband Direct Conversion Transmitter/Receiver at D-band Using CMOS 22nm FDSOI," RFIC, Boston, MA, USA, 2019, pp. 135-138.

[4] M. Kucharski, H. J. Ng and D. Kissinger, "An 18 dBm 155-180 GHz SiGe Power Amplifier Using a 4-Way T-Junction Combining Network," ESSCIRC 2019, Cracow, Poland, 2019, pp. 333-336.

[5] A. Visweswaran et al., "A 112-142GHz Power Amplifier with Regenerative Reactive Feedback achieving 17dBm peak Psat at 13% PAE," ESSCIRC, Cracow, Poland, 2019, pp. 337-340.

[6] Z. Furqan et al., "A 15.5-dBm 160- GHz high-gain power amplifier in SiGe BiCMOS technology," IEEE Microwave. Wireless Component. Lett., vol. 27, no. 2, pp. 177–179, Feb. 2017.

[7] Z. Griffith, M. Urteaga and P. Rowell, "A 140-GHz 0.25-W PA and a 55-135 GHz 115-135 mW PA, High-Gain, Broadband Power Amplifier

MMICs in 250-nm InP HBT," IMS, Boston, MA, USA, 2019, pp. 1245- 1248.

[8] Z. Griffith, M. Urteaga and P. Rowell, "A Compact 140-GHz, 150-mW High-Gain Power Amplifier MMIC in 250-nm InP HBT," in IEEE Microwave and Wireless Components Letters, vol. 29, no. 4, pp. 282-284, April 2019.

[9] M. Urteaga, Z. Griffith, M. Seo, J. Hacker, M. Rodwell, "InP HBT Technologies for THz Integrated Circuits", Proceedings of the IEEE, Vol. 105, No. 6, pp 1051-1067 June 2017.

[10] Cripps, S 'RF Power amplifiers for wireless communications', 2nd Edition, Artech House, 2006, ISBNI-S96-93-018-7, sec 3.7 pp. 61-6S.

[11] H. T. Dabag, et al., "Analysis and Design of Stacked-FET Millimeter-Wave Power Amplifiers," IEEE Trans. MTT, vol. 61, no. 4, pp. 1543-1556, April 2013.

[12] A. S. H. Ahmed, A. A. Farid, M. Urteaga and M. J. W. Rodwell, "204GHz Stacked-Power Amplifiers Designed by a Novel Two-Port Technique," 2018 13th European Microwave Integrated Circuits Conference (EuMIC), Madrid, 2018, pp. 29-32.

[13] A. S. H. Ahmed, A. Simsek, M. Urteaga and M. J. W. Rodwell, "8.6-13.6 mW Series-Connected Power Amplifiers Designed at 325 GHz Using 130 nm InP HBT Technology," 2018 IEEE BiCMOS and Compound Semiconductor Integrated Circuits and Technology Symposium (BCICTS), San Diego, CA, 2018, pp. 164-167.

[14] Z. Griffith, M. Urteaga, P. Rowell, R. Pierson and M. Field, "Multi-finger 250nm InP HBTs for 220GHz mm-wave power," 2012 International Conference on Indium Phosphide and Related Materials, Santa Barbara, CA, 2012, pp. 204-207.

[15] T. B. Reed, Z. Griffith, P. Rowell, M. Field and M. Rodwell, "A 180mW InP HBT Power Amplifier MMIC at 214 GHz," (CSICS), Monterey, CA, 2013, pp. 1-4.
 [16] Ahmed S. H. Ahmed, Munkyo Seo, Ali A. Farid, Miguel Urteaga, James F. Buckwalter, and Mark J. W. Rodwell, "A 200mW D-band Power Amplifier with 17.8% PAE in 250-nm InP



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18